INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Multiple sheets used when necessary) SHEET 1 OF 1 Application No. Filing Date First Named Inventor Art Unit Examiner Attorney Docket No.

	Application No.	10/507,923
	Filing Date	July 19, 2005
	First Named Inventor	Cedric Szpirer
	Art Unit	1633
Ī	Examiner	Kevin Kai Hill
	Attorney Docket No.	VANM290.001APC

			U.S. PATENT	DOCUMENTS	
Examiner Initials	Cite Na.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
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Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ¹

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ¹
	1	Kristoffersen et al., "Bacterial Toxin-Antitoxin Gene System as Containment Control in Yeast Cells," Applied and Environmental Microbiology, Dec 2000, Vol. 66 no. 12, p. 5524-5526.	
	2	Metzger et al., "The Nucleotide Sequence and Characterization of the relA Gene of Escherichia coli," Journal of Biological Chemistry, October 25, 1988, Vol. 263 no. 30, p. 15699-15704.	
	3	Tamamoto et al., "Bacterial Toxin RelE Induces Apoptosis in Human Cells," FEBS Letters, 2002, 519, p.191-194.	
	4	Zielenkiewcz et al., "Mechanisms of Plasmid Stable Maintenance with Special Focus on Plasmid Addiction Systems," Acta Biochimica Polonica, 2001, Vol. 48 no. 4, p. 1003-1023.	

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*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.